



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Appl. No.:

10/706,600

Confirmation No.: 5854

Applicant(s):

Hamada et al.

Filed:

11/12/2003

Title:

COMPOSITION FOR FORMING POROUS FILM, POROUS FILM AND

METHOD FOR FORMING THE SAME, INTERLEVEL INSULATOR FILM, AND

SEMICONDUCTOR DEVICE

Docket No.:

035576/271448

Customer No.: 00826

June 25, 2004

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

PRELIMINARY AMENDMENT 37 CFR § 1.115

Sir:

Please enter this Preliminary Amendment before calculating the claim fee and amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims beginning on page 2 of this paper.

Remarks begin on page 5 of this paper.